

CUSTOMER NO.: 27623

FORM PTO-1449  INFORMATION DISCLOSURE CITATION IN AN APPLICATION  (Use several sheets if necessary)	Docket Number (Optional)	Application Number
	2133.061USU	Not Yet Assigned
	Applicant	
	Mund and Leib	
Filing Date	Group Art Unit	
Herewith	Not Yet Assigned	

## U. S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
HEA	4,104,418	8/1/78	Park et al.	427	42	
HEA	4,737,252	4/12/88	Hoffman	204	192.16	

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
HEA	DE10222609.1A1	5/23/02	Germany				X
HEA	DE10222958.9A1	5/23/02	Germany				X
HEA	DE10222964.3A1	5/23/02	Germany				X
HEA	DE10252787.3A1	11/13/02	Germany				X
HEA	DE10301559.0A1	10/30/03	Germany				X
HEA	387175	5/15/65	Switzerland				X

## OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, Etc.)

HEA	XP-000819426, Sputtered Lead Silicate Glass Film for Multilevel Interconnections, Kato et al., 2419 Japanese Journal of Applied Physics Supplements, vol. 22 (1983) suppl. No. 22-1, Tokyo, Japan, pgs 167-170
HEA	XP-002251599, Eliminating The Step in Etched via Holes Interrupted Sputter Glass Deposition, Bialko et al., vol. 20, no. 7 (1977), IBM Technical Disclosure Bulletin, pg 26.

EXAMINER <i>Michael Albert</i>	DATE CONSIDERED 10/13/05
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP §609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.